

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: M. HATANO, et al.

Application No.: Rule 1.53(b) Divisional of U.S. Patent Application Serial
No. 09/791,853, filed February 26, 2001

Filed: On even date herewith

For: THIN FILM SEMICONDUCTOR DEVICE,
POLYCRYSTALLINE SEMICONDUCTOR THIN
FILM PRODUCTION PROCESS AND PRODUCTION
APPARATUS

Art Group of Parent: 2823

Examiner of Parent: M. Estrada

PRELIMINARY AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

September 26, 2003

Sir:

Prior to examination, please amend the above-identified application as listed
below and as set forth on the following pages:

Amendments to the Specification

Remarks are included following the amendments.